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Docket No.: M-12396 US

November 15, 2001

Box Patent Application
Commissioner For Patents
Washington, D. C. 20231

Enclosed herewith for filing is a patent application, as follows:

Inventor(s): Turner, Michael; Fung, Waikit; Graudejus, Oliver; Winandy, Doug
Title: Phosphorous-Doped Silicon Dioxide Process To Customize Contact Etch Profiles

- ☒ Return Receipt Postcard
☒ This Transmittal Letter (in duplicate)
1 page NonPublication Request
3 page(s) Declaration For Patent Application and Power of Attorney (unsigned)
8 page(s) Specification (not including claims)
4 page(s) Claims
1 page Abstract
5 Sheet(s) of Drawings
1 page(s) PTO Form 1449 citing 6 references
☒ Copy(ies) of 6 Cited References submitted

CLAIMS AS FILED

For	Number Filed		Number Extra		Rate		Basic Fee
Total Claims	20	-20 =	0	x	\$18.00	=	\$ 0.00
Independent Claims	2	-3 =	0	x	\$84.00	=	\$ 0.00
<input type="checkbox"/>	Fee of _____ for the first filing of one or more multiple dependent claims per application						\$
<input type="checkbox"/>	Fee for Request for Extension of Time						\$

Please make the following charges to Deposit Account 19-2386:

- ☒ Total fee for filing the patent application in the amount of \$ 740.00
☒ The Commissioner is hereby authorized to charge any additional fees which may be
required, or credit any overpayment to Deposit Account 19-2386.

EXPRESS MAIL LABEL NO:

EL 884 815 769 US

Respectfully submitted,

R. Leiterman

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MODIFIED PTO/SB/35 (11-00)

REQUEST AND CERTIFICATION UNDER 35 U.S.C. 122(b)(2)(B)(i)	Inventors	Michael Turner et al.
	Title	Phosphorus-Doped Silicon Dioxide Process To Customize Contact Etch Files
	Atty Docket Number	M-12396 US

I hereby certify that the invention disclosed in the attached application **has not and will not be** the subject of an application filed in another country, or under a multilateral agreement, that requires publication at eighteen months after filing. I hereby request that the attached application not be published under 35 U.S.C. 122(b).

November 15, 2001

Date



Rachel V. Leiterman
Attorney for Applicants
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This request must be signed in compliance with 37 CFR 1.33(b) and submitted with the application **upon filing**.

Applicant may rescind this nonpublication request at any time. If applicant rescinds a request that an application not be published under 35 U.S.C. 122(b), the application will be scheduled for publication at eighteen months from the earliest claimed filing date for which a benefit is claimed.

If applicant subsequently files an application directed to the invention disclosed in the attached application in another country, or under a multilateral international agreement, that requires publication of applications eighteen months after filing, the applicant **must** notify the United States Patent and Trademark Office of such filing within forty-five (45) days after the date of the filing of such foreign or international application. **Failure to do so will result in abandonment of this application (35 U.S.C. 122(b)(2)(B)(iii)).**